

IN THE SPECIFICATION:

Please amend paragraph [0009] as follows:

[0009] A radiation-patterning tool 20 typically includes an obscuring material that may either be an opaque (e.g., chrome) or a semi-opaque material placed over a transparent material (e.g., glass). Radiation-patterning tool 20 is illustrated in FIG. 2 as having a front side 28 for forming features or windows and an opposing back side 26. Some radiation-patterning tools further utilize both the front side and ~~backside~~ back side for the formation of windows.

Please amend paragraph [0016] as follows:

[0016] FIG. 9 illustrates a portion of a prior art radiation-patterning tool 34 similar to the tool described with reference to FIG. 4, except that FIG. 9 further illustrates a sidelobe inhibitor 62 for preventing sidelobes of radiation from combining when passing through elements 36. Sidelobe inhibitor 62 typically includes dimensions of approximately one-half of the wavelength of the radiation passed through radiation-patterning tool 34. Sidelobe inhibitor 62 may be formed, for example, by etching onto an opaque material associated with radiation-patterning tool 34 to form a region where radiation will be in phase with the main energy lobe and thus out of phase relative to other portions of the sidelobe radiation. Such a combination is typically known as destructive interference, which results in a cancellation of a significant amount of intensity from the combined sidelobes.